

UKNC Conference Programme



Swansea University

7th-8th January 2026

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Any participants who have concerns that the Code of Conduct has been breached should contact one of the UKNC committee members responsible for conferences:

Prof David Binks: david.binks@manchester.ac.uk

Dr Matt Smith: matt.smith@bristol.ac.uk

Prof Rachel Oliver: rao28@cam.ac.uk

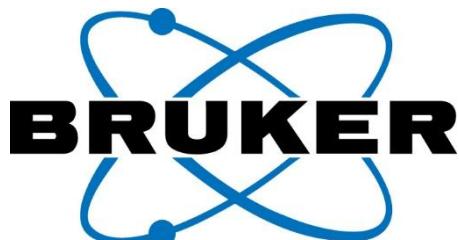
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AIXTRON



TAIYO NIPPON SANSO

iQE



IOP Institute of Physics

Wednesday 7th of January 2026.

09:30-10:10 Arrival, Registration and Coffee (sponsored by Taiyo Nippon Sanso)
Computational Foundry, Ground Floor Foyer and Networking Space
(Room 001)

10:10-10:15 Welcome and Opening Remarks
Computational Foundry, Lecture Theatre 002

10:15-11.00 Invited Talk - Chair: Prof. Rachel Oliver
Computational Foundry, Lecture Theatre 002

Exploring electrochemical etching as a tool for cladding engineering in III-nitride laser diodes

Marta Sawicka

Institute of High Pressure Physics Polish Academy of Sciences (IHPP PAS), Warsaw, Poland

11.00-12.00 Session 1: Optoelectronics - Chair: Prof. Rachel Oliver
Computational Foundry, Lecture Theatre 002

11.00-11.15 **Linearly Polarised Emission from C-Plane InGaN Quantum Dots Grown by MOVPE**

C. Zhao¹, Z. S. Pehlivan¹, G. Kusch¹, M. J. Kappers¹, R. A. Oliver¹

¹*University Of Cambridge, Cambridge, United Kingdom*

11.15-11.30 **Porosity and relaxation in Al-rich AlGaN**

E. Jaaskelainen¹, T. R. Harris-Lee¹, M. Grigoletto², A. Chatterjee¹, M. Frentrup¹, M. J. Kappers¹, T. Wernicke², M. Kneissl², R. A. Oliver¹, G. Kusch¹

¹ Department of Materials Science and Metallurgy, University of Cambridge, United Kingdom, ²Institute of Solid State Physics, Technische Universität Berlin, Germany

11.30-11.45 **Pathways to Efficient Red Micro-LEDs: Analysis of 100-mm InGaN-on-Silicon Wafer**

K. Nicholson¹, R. Alshammary¹, N. Zarrabi², S. Wood², T. Wang¹, N. Gunasekar¹

¹*School of Physics and Astronomy, Cardiff University, The Parade, Cardiff, UK, CF24 3AA*

²*National Physical Laboratory (NPL), Teddington, Middlesex, UK*

11.45-12.00 **Development of GaN Micro-Pyramids and Platelets with High Uniformity for micro-LED applications**

C. Li¹, V. Zubialevich¹, P. Parbrook¹, B. Corbett¹, Z. Li¹

¹*Tyndall National Institute, , Ireland*

12.00-13.00 **Lunch**
Computational Foundry, Ground Floor Foyer

13.00-13.45 The Humphreys Lecture - Chair: Dr. Matt Smith
Computational Foundry, Lecture Theatre 002

Current Transport in AlN Schottky Barrier Diode

Takuya Maeda

University of Tokyo, Japan

13.45-14.45 Session 2: Electrical Devices - Chair: Dr. Matt Smith
Computational Foundry, Lecture Theatre 002

13.45-14.00 **Investigation of Leakage Current Paths in GaN-Based Nanoribbon Devices**

B. Ubochi¹, K. Ahmeda², B. Benbakhti³, **K. Kalna**⁴

¹Department of Electrical and Electronics Engineering, School of Electrical Systems Engineering, The Federal University of Technology, Nigeria, ²Dynex Semiconductor, Ltd., United Kingdom, ³Liverpool John Moores University, ⁴Swansea University, United Kingdom

14.00-14.15 **Resistance Contributions to Quasi-Vertical GaN-on-SiC MOSFETs at Elevated Temperature**

J. Evans¹, F. Monaghan¹, R. Harper², A. B. Khaial¹, M. Elwin¹, M. Jennings¹

¹Centre for Integrative Semiconductor Materials and Department of Physics, Swansea University, Bay Campus, Fabian Way, Swansea SA1 8EN, United Kingdom, ²Compound Semiconductor Centre Ltd, St. Mellons, Cardiff, United Kingdom

14.15-14.30 **Investigation of Forward Current Behaviour in a Thin Barrier AlGaN/GaN Schottky Diode at Cryogenic Temperatures**

N. Suphannarat¹, S. Ghosh¹, A. Chatterjee¹, F. Adams¹, M. Kappers¹, D. Wallis¹, R. Oliver¹

¹Department of Materials Science & Metallurgy, University of Cambridge, United Kingdom

14.30-14.45 **Terahertz detection via the in-plane photoelectric effect in 2D electron systems: from AlGaAs/GaAs HEMTs to AlGaN/GaN HEMTs**

R. Chen¹, M. Tan¹, S. Ghosh², M. J. Kappers³, H. E. Beere¹, R. A. Oliver³, D. A. Ritchie^{1, 2}, **W. Michailow**¹

¹Cavendish Laboratory, University of Cambridge, Cambridge CB3 0HE, United Kingdom,

²Centre for Integrative Semiconductor Materials and Department of Physics, Swansea University, Bay Campus, Fabian Way, Swansea SA1 8EN, United Kingdom, ³Department of Materials Science and Metallurgy, University of Cambridge, Cambridge CB3 0FS, United Kingdom

14.45-15.15 Coffee (sponsored by IQE)
Networking space (001)

15.15-16.15 Session 3: Emerging Materials, Defects and Characterization - Chair: Dr. Fabien Massabuau
Computational Foundry, Lecture Theatre 002

15.15 -15.30 **Controlled growth of defects in gallium nitride that emit quantum light at room temperature**
K. Eggleton¹, J. Cannon¹, S. Bishop¹, J. Hadden¹, C. Zhou², M. Kappers², R. Oliver², A. Bennett¹
¹*Cardiff University, Cardiff, United Kingdom, ²University of Cambridge, United Kingdom*

15.30 -15.45 **On the origin of deep-level defects E1 and E3 in GaN and dilute AlGaN alloys**
P. Kruszewski¹, V. Markevich², **C. Dawe**², J. Coutinho³, L. Sun², P. Prystawko¹, J. Plesiewicz¹, M. Halsall², D. Binks², A. Peaker²
¹*Institute of High Pressure Physics and Polish Academy of Sciences, Poland, ²Photon Science Institute, The University of Manchester, United Kingdom, ³i3N and Department of Physics, University of Aveiro, , Portugal*

15.45 -16.00 **Fundamental properties of boron containing III-nitrides alloys: Combining an empirical atomistic valence force field model with density functional theory for future large scale simulations**
A. Power^{1,2}, C. Nies¹, S. Schulz^{1,2}
¹*Tyndall National Institute, University College Cork, Ireland, ²School of Physics, University College Cork, Ireland*

16.00 -16.15 **Overview of AFM characterization methods for Nitride materials**
J. Qi¹, **M. Febvre**², P. Dewolf²
¹*Bruker UK, United Kingdom, ²Bruker France, France*

16:15-17:30 Host introduction and facility tour

16.15 -16.30 **Introduction to the Centre for Integrated Semiconductor Materials (CISM) facility**
S. Ghosh¹
¹*Centre for Integrative Semiconductor Materials (CISM) and faculty of science and Engineering, Swansea University, SA1 8EN Swansea, UK, United Kingdom*

16.30 -17.30 **Facility tour**
CISM building

17.15-18.15 AGM
Computational Foundry, Lecture Theatre 002

19.00 Drinks Reception & Conference Dinner (sponsored by AIXTRON)
The National Waterfront Museum, Marina

Thursday 8th of January 2026

09.00-09.45 Foxon Lecture - Chair: Prof. Martin Kuball
Computational Foundry, Lecture Theatre 002

Vertical GaN power devices on native and non-native substrates

Matthew Smith

University of Bristol, Bristol, UK

09.45-10.45 Session 4: Gallium Oxide - Chair: Prof. Martin Kuball
Computational Foundry, Lecture Theatre 002

09.45 -10.00 **On the nature of electrically active deep-level defects in silicon doped MOCVD grown β -Ga₂O₃ epilayers**

C. Dawe¹, D. M. Lendering¹, V. Markevich¹, J. Jacobs², I. Hawkins², M. Halsall², A. Peaker³, A. Nandi¹, M. Kuball¹ and Naresh Gunasekar¹

¹Photon Science Institute and Department of Electrical and Electronic Engineering, University Of Manchester, Manchester, United Kingdom, ²Centre for Device Thermography and Reliability (CDTR), HH Wills Physics Laboratory, University of Bristol, United Kingdom

10.00 -10.15 **Exploring Temperature induced effects when growing amorphous Ga₂O₃ using Close Coupled Showerhead MOCVD**

A. Moore¹, C. Llewelyn², D. Lamb², L. Li¹

¹Centre for Integrative Semiconductor Materials (CISM) and faculty of science and Engineering, Swansea University, SA1 8EN Swansea, UK, United Kingdom, ²The Oxide and Chalcogenide Facility, Centre for Integrative Semiconductor Materials (CISM), Faculty of Science and Engineering, Bay Campus, Swansea University, SA1 8EN, UK, United Kingdom

10.15 -10.30 **Wafer-scale MBE of two-dimensional GaSe semiconductors and its post-growth conversion to Ga₂O₃**

S. Novikov¹, T. S. Cheng¹, J. Bradford¹, N. D. Cottam¹, M. Shiffa¹, K. Rahman¹, S. Alghamdi¹, B. T. Dewes¹, A. A. Alzeer¹, M. Mundslinger², J. Biskupek², U. Kaiser^{2, 3}, T. Klee⁴, J. J. Broughton⁴, C. J. Mellor¹, O. Makarovskiy¹, P. H. Beton¹, T. Ben⁵, D. Gonzalez⁵, J. W. G. Tisch⁴, J. N. O'Shea¹, A. Patanè¹

¹University Of Nottingham, Nottingham, United Kingdom, ²Ulm University, , Germany,

³Institute for Quantum Optics, Ulm University, , Germany, ⁴Imperial College London, , United Kingdom, ⁵Universidad de Cadiz, Spain

10.30 -10.45 **Electron microscopy investigation of laterally overgrown α -Ga₂O₃**

L. Penman¹, M. Maruzane¹, Y. Oshima², P. Edwards¹, R. Martin¹, F. Massabuau¹

¹University Of Strathclyde, Glasgow, United Kingdom, ²National Institute for Materials Science, Japan

10.45-11.15 Coffee break (sponsored by Taiyo Nippon Sanso)
Networking space (001)

11:15-12:15 Session 5: Zinc-blende Gallium Nitride - Chair: Prof. Peter Parbrook
Computational Foundry, Lecture Theatre 002

11.15-11.30 Correlative CL-SEM and CL-STEM microscopy to understand dopant segregation in Mg doped Cubic Gallium Nitride

S. Fairclough¹, M. Frentrup¹, Z. Zhou², S. Roberston², M. Kappers¹, K. Bukvišová³, C. C. Mitterbauer³, J. Maniš³, S. Vespucci³, C. Ozsoy-Keskinbora³, D. Wallis^{1,4}, R. Oliver¹, G. Kusch¹

¹*University Of Cambridge, Cambridge, United Kingdom*, ²*Loughborough University, United Kingdom*, ³*Thermo Fisher Scientific, Netherlands*, ⁴*Cardiff University, United Kingdom*

11.30-11.45 Thermodynamic and Electronic Properties of Wurtzite and Zincblende Based GaN Alloved Compounds

M. M. Islam¹, Z. Wang¹, D. Bowler¹
¹*Cardiff University, United Kingdom*

11.45-12.00 Multi-microscopy study of an on-axis zincblende InGaN/GaN single quantum well sample

X. Xu¹, M. Frentrup¹, A. Power³, Z. S. Pehlivan¹, G. Kusch¹, M. J. Kappers¹, S. Schulz³, D. J. Wallis^{1,2}, R. A. Oliver¹

¹*University Of Cambridge, Cambridge, United Kingdom*, ²*Centre for High Frequency Engineering, University of Cardiff, United Kingdom*, ³*School of Physics, Tyndall National Institute, University College Cork, Ireland*

12.00-12.15 Polarisation-Resolved Optical Properties of an MOVPE Grown Cubic InGaN/GaN Quantum Well on 3C-SiC/Si Substrate

W. Fieldhouse-Allen¹, M. Kappers², M. Frentrup², D. Wallis³, R. Oliver², D. Binks¹
¹*Department of Physics and Astronomy, University of Manchester, United Kingdom*,
²*Department of Materials Science & Metallurgy, University of Cambridge, United Kingdom*, ³*Centre for High Frequency Engineering, Cardiff University, United Kingdom*

12:15- 13:15 Flash Presentations for posters
Computational Foundry, Lecture Theatre 002
2 minutes per poster (maximum of a title slide plus two other slides)

13:15- 14:30 Lunch & Poster Session
Computational Foundry, Ground Floor Foyer and Networking Space
(Room 001)

14:30- 15:45 Session 6: Ultrawide Bandgap Devices - Prof. David Wallis
Computational Foundry, Lecture Theatre 002

14.30 -14.45 **Achieving n- and p-type conductivity in high Al-content AlGaN by MOVPE for developing AlGaN-based vertical transistors**

A. Chatterjee¹, Z. Pehlivan¹, Y. Yin², M. Frentrup¹, S. A. Dar¹, M. J. Kappers¹, M. D. Smith², D. J. Wallis³, M. Kuball², R. A. Oliver¹

¹*University Of Cambridge, Cambridge, United Kingdom*, ²*University of Bristol, United Kingdom*, ³*Cardiff University, United Kingdom*

14.45 -15.00 **Ohmic contact development for Al-rich channel high electron mobility transistors**

Dr. Jayjit Mukherjee¹, Pietro Pampili¹, Badal Mondal¹, Peter James Parbrook^{2,3}, Stefan Schulz^{2,4}, David Moran¹

¹*James Watt School of Engineering, University of Glasgow, Glasgow G12 8LT, Glasgow, United Kingdom*, ²*Tyndall National Institute, University College Cork, Cork T12 R5CP, Ireland*, ³*School of Engineering, University College Cork, Western Road, Cork, Ireland*, ⁴*School of Physics, University College Cork, Cork T12 YN60, Ireland*

15.00 -15.15 **Design and Performance Outlook of Ultrawide Bandgap AlGaN Power Electronics**

Y. Yin¹, M. Smith¹, J. Pomeroy¹, M. Kuball¹,

¹*Center for Device Thermography and Reliability, University of Bristol, Tyndall Avenue, Bristol, United Kingdom*

15.15 -15.30 **Surface study and influence of native oxides on the sheet resistance of Al-rich channel high electron mobility transistors**

Dr. Jayjit Mukherjee¹, Badal Mondal¹, Pietro Pampili¹, Christopher Kelly³, Peter James Parbrook^{2,4}, Stefan Schulz^{2,5}, David Moran¹

¹*James Watt School of Engineering, University of Glasgow, Glasgow G12 8LT, Glasgow, United Kingdom*, ²*Tyndall National Institute, University College Cork, Cork T12 R5CP, Ireland*, ³*School of Chemistry, University of Glasgow, Glasgow, G12 8QQ, United Kingdom*, ⁴*School of Engineering, University College Cork, Western Road, Cork, Ireland*, ⁵*School of Physics, University College Cork, Cork T12 YN60, Ireland*

15.30 -15.45 **Normally-off N-polar GaN/AlN transistors with p-NiO gate stacks**

C. Zhang¹, Y. Yin¹, P. Huang¹, I. Furuhashi², M. Pristovsek², M. Kuball¹, M. D. Smith¹

¹*Center for Device Thermography and Reliability, University of Bristol, Bristol, Bristol, United Kingdom*; ²*Center for Innovative Research of Future Electronics, Nagoya University, Nagoya, Japan*

15:45-16:00 Closing Remarks & Student Prizes
Computational Foundry, Lecture Theatre 002

16:00 Depart

Posters (8th Jan 2026 13.15-14:30)

Computational Foundry, Ground Floor Foyer and Networking Space
(Room 001)

1. Heteroepitaxial Growth and In Situ Si Doping of β -Ga₂O₃ Thin Films on Miscut Sapphire 6.0° Using a MOCVD Close-Coupled Showerhead Reactor

Ciaran Llewelyn¹, Dan Lamb¹

¹*The Oxide and Chalcogenide Centre, Centre for Integrative Semiconductor Materials (CISM) and Faculty of Science and Engineering, Swansea University, Swansea, SA1 8EN, UK, Swansea, United Kingdom*

2. Automated Quantification and Classification of Threading Dislocations in GaN using AFM and Deep Learning

Mr Cobi Allen¹, Aisha Mariam¹, Jiawei Zhang¹, Gunnar Kusch¹

¹*University Of Cambridge, , United Kingdom*

3. Investigating the effect of the NH₃ pre-dose time on compressive strain and threading dislocation density in GaN-on-Si structures

Miss Aisha Mariam¹, Martin Frentrup¹, Petr Vacek¹, Menno J Kappers¹, Rachel A Oliver¹

¹*University Of Cambridge, United Kingdom*

4. Drift–Diffusion Computation for High-Voltage Optimization of β -Ga₂O₃ FinFETs

Nicholas edwards¹, Antonio Muniz¹, Jon Evans¹, Jacob Mitchel¹, Owen Guy¹, Huma Ashraf¹, Mike Jennings¹

¹*Swansea University, Swansea, United Kingdom*

5. Theoretical characterization of the Wurzite and Zincblende GaN stacking faults

Dr Mohammad Mazharul Islam¹, Zijie Wang¹, David Bowler¹

¹*Cardiff University, Cardiff, United Kingdom*

6. Low Earth Orbit Radiation Response and Photoconduction of β -(Al_xGa_{1-x})₂O₃ Alloys

Farnaz Hadizadeh¹, Sean douglas³, Arpit Nandi³, Sai Charan Vanjari², Viesturs Spūlis¹, Robbie Wilson¹, Ross Gray¹, Stephen Reynolds³, Daniel Oi¹, Susan Spesvtseva¹, Paul McKenna¹, Robert Martin¹, Martin Kuball², David Keeble³, Matthew Smith², Fabien Massabuau¹

¹*Department of Physics, SUPA, University of Strathclyde, Glasgow, UK, , United Kingdom,*

²*Department of Physics, University of Bristol, Bristol, UK, , United Kingdom, ³School of Science and Engineering, University of Dundee, Dundee, UK, , United Kingdom*

7. Optimisation of porous GaN distributed Bragg reflectors using low concentration electrochemical etching

Ben Thornley¹, Zetai Xu¹, Thom R. Harris-Lee¹, Menno Kappers¹, Piotr Sokolinski¹, Rachel A. Oliver¹

¹*Department of Materials Science and Metallurgy, University of Cambridge, , United Kingdom*

8. Stability of AlGaN/GaN HEMTs and Schottky diodes on Si irradiated by 60Co gamma rays

Sami Kibal¹, Menno Kappers¹, Ruth Edge², Emil Jonasson³, Rachel Oliver¹

¹*University Of Cambridge, Cambridge, United Kingdom, ²Dalton Cumbrian Facility, University of Manchester, , United Kingdom, ³Remote Applications for Challenging Environments (RACE), UK Atomic Energy Authority (UKAEA), , United Kingdom*

9. Electron-irradiation-induced EE1 trap in GaN: unusual electronic properties of a defect linked to the nitrogen vacancy

Christopher Dawe¹, Piotr Kruszewski², Vladimir Markevich¹, José Coutinho³, Lijie Sun¹, Paweł Prystawko², Jerzy Plesiewicz², Matthew Halsall¹, Anthony Peaker¹

¹*Photon Science Institute, The University Of Manchester, , United Kingdom*, ²*Institute of High Pressure Physics and Polish Academy of Sciences, , Poland*, ³*i3N and Department of Physics, University of Aveiro, , Portugal*

10. Mesa-Terminated Vertical GaN Diodes: Substrate-Dependent Performance Limits

Mritunjay Kumar¹, Chengzhi Zhang¹, Martin Kuball¹, Matthew Smith¹

¹*CDTR, HH Wills Physics Laboratory, University of Bristol, Bristol, United Kingdom*

11. Time-of-Flight Elastic Recoil Detection Analysis of Proton Induced Compositional Changes in Wide Band Gap Perovskites for Space Applications

Dr Matthew Sharpe¹, Hongjae Shim², Callum McAleese¹, Jae Yun³

¹*Surrey Ion Beam Centre, University Of Surrey, GUILDFORD, United Kingdom*, ²*Australian Centre for Advanced Photovoltaics (ACAP), School of Photovoltaic and Renewable Energy Engineering, University of New South Wales, , Australia*, ³*Advanced Technology Institute, University of Surrey, , United Kingdom*

12. Effect of indium composition on the light emission from MOVPE-grown cubic $In_xGa_{1-x}N$ epilayers

Haoyang Sun¹, Daniel Dyer¹, Menno Kappers², Martin Frentrup², David Wallis^{2,3}, Rachel Oliver², David Binks¹

¹*Photon Science Institute & Department of Physics and Astronomy, University of Manchester, Manchester, United Kingdom*, ²*Department of Materials Science and Metallurgy, University of Cambridge, Cambridge, , United Kingdom*, ³*Centre for High Frequency Engineering, Cardiff University, Cardiff, , United Kingdom*

13. Homogeneity Evaluation and Single Pallet Characterization of UV-B Micro-LED Structures using Cathodoluminescence

Rong Teng¹, Oliver Short¹, Zeki S. Pehlivan¹, Rachel A. Oliver¹, Gunnar Kusch¹

¹*Department of Material Science and Metallurgy, University of Cambridge, , United Kingdom*

14. Morphology of Gallium Oxide Thin Films on c-axis Sapphire Grown by Metal Oxide Chemical Vapour Deposition (MOCVD)

Ms Shreyasi Maitra^{1,2}, Dan Lamb², Indraneel Sanyal³, Ciaran Llewelyn², Paul Meredith^{2,4}, David Ritchie², Saptarsi Ghosh^{1,2}

¹*Department of Electronic and Electrical Engineering, Swansea University, Swansea, United Kingdom*, ²*Centre for Integrative Semiconductor Materials, Swansea University, Swansea, , United Kingdom*, ³*AIXTRON PLC, Buckingway Business Park, Swavesey, Cambridge, , United Kingdom*, ⁴*Department of Physics, Swansea University, Swansea, , United Kingdom*

15. Dependence of the Ohmic Process on the Temperature-Dependent Characteristics of AlGaN/GaN Heterostructure Diodes

NITISH RANA¹, Saptarsi Ghosh^{1,2}, Mike Jennings^{1,2}, John Evans², Ahmed Benkhaial², Nick Edwards²

¹*Department of Electronic and Electrical Engineering, Swansea University, , United Kingdom*, ²*Centre for Integrative Semiconductor Materials, Swansea University, , United Kingdom*

16. An initial study of electrochemical porosification of Mg-doped p-type GaN

Jiawei Zhang¹, Thom Harris-Lee¹, Menno Kappers¹, Rachel Oliver¹

¹*University Of Cambridge, Cambridge, United Kingdom*

17. Origin and properties of p-layer surface hillocks in AlGaN-based deep-UV LEDs

Viesturs Spūlis^{1,2}, Christoph Margenfeld³, Paul R. Edwards¹, Gunnar Kusch², Andreas Waag³,

Robert W. Martin¹

¹*University of Strathclyde, , United Kingdom*, ²*University of Cambridge, , United Kingdom*,

³*Technische Universität Braunschweig, , Germany*

18. Impact of anisotropic strain on the electronic and optical properties of zincblende (In,Ga)N quantum wells

Aisling Power¹, D. Dyer², W. Fieldhouse-Allen², X. Xu³, M. Frentrup³, Z. S. Pehlivan³, G. Kusch³, M. J. Kappers³, D. J. Wallis^{3,4}, R. A. Oliver³, D. J. Binks², S. Schulz¹

¹*School of Physics & Tyndall National Institute, University College Cork, , Ireland*, ²*Department of Physics and Astronomy & Photon Science Institute, University of Manchester, , United Kingdom*,

³*Department of Materials Science and Metallurgy, University of Cambridge, United Kingdom*,

⁴*Centre for High Frequency Engineering, University of Cardiff, , United Kingdom*

19. Effects of carbon-doped buffer thickness and back-barrier structures on the electrical behaviour of GaN HEMTs

Zubear Nowshad Pasha¹, Christopher Dawe², Matthew Halsall², Iwan Davies³, Naresh Gunasekar¹

¹*School of Physics and Astronomy, Cardiff University, The Parade, Cardiff, CF24 3AA, UK*

²*Department of Electrical and Electronic Engineering, The University of Manchester, Manchester, M139PL, UK*

²*IQE plc, Pascal Close, St. Mellons, Cardiff CF3 0LW, United Kingdom*